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## \*BIBDATASHEET\*

CONFIRMATION NO. 8611

Bib Data Sheet

SERIAL NUMBER 10/092,203	FILING DATE 03/04/2002  RULE	CLASS 438	GROUP ART UNIT 2812	ATTORNEY DOCKET NO. AMAT/6218/DD/LOW K/JW
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APPLICANTS

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\*\* CONTINUING DATA \*\*\*\*\*  
*J.H.* NONE

\*\* FOREIGN APPLICATIONS \*\*\*\*\*  
*J.H.* NONE

IF REQUIRED, FOREIGN FILING LICENSE GRANTED  
 \*\* 04/09/2002

Foreign Priority claimed <input type="checkbox"/> yes <input checked="" type="checkbox"/> no 35 USC 119 (a-d) conditions met <input type="checkbox"/> yes <input checked="" type="checkbox"/> no <input type="checkbox"/> Met after Allowance Verified and Acknowledged <i>Examiner's Signature</i> <i>Initials</i>	STATE OR COUNTRY CA	SHEETS DRAWING 1	TOTAL CLAIMS 39	INDEPENDENT CLAIMS 3
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ADDRESS  
 32588  
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TITLE  
 Method of depositing a low k dielectric barrier film for copper damascene application

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